



(19) **United States**

(12) **Patent Application Publication**  
**Wang et al.**

(10) **Pub. No.: US 2019/0006085 A1**

(43) **Pub. Date: Jan. 3, 2019**

(54) **INFO COIL ON METAL PLATE WITH SLOT**

**Publication Classification**

(71) Applicant: **Taiwan Semiconductor Manufacturing Company, Ltd.**,  
Hsinchu (TW)

(51) **Int. Cl.**  
**H01F 27/28** (2006.01)  
**H01F 27/36** (2006.01)  
**H01F 38/14** (2006.01)  
**H05K 1/16** (2006.01)

(72) Inventors: **Chuei-Tang Wang**, Taichung City (TW); **Wei-Ting Chen**, Tainan City (TW); **Chieh-Yen Chen**, Taipei City (TW); **Hao-Yi Tsai**, Hsinchu (TW); **Ming Hung Tseng**, Toufen Township (TW); **Hung-Yi Kuo**, Taipei City (TW); **Chen-Hua Yu**, Hsinchu (TW)

(52) **U.S. Cl.**  
CPC ..... **H01F 27/2804** (2013.01); **H01F 27/362** (2013.01); **H01F 2027/2809** (2013.01); **H05K 1/165** (2013.01); **H01F 38/14** (2013.01)

(21) Appl. No.: **16/125,923**

(57) **ABSTRACT**

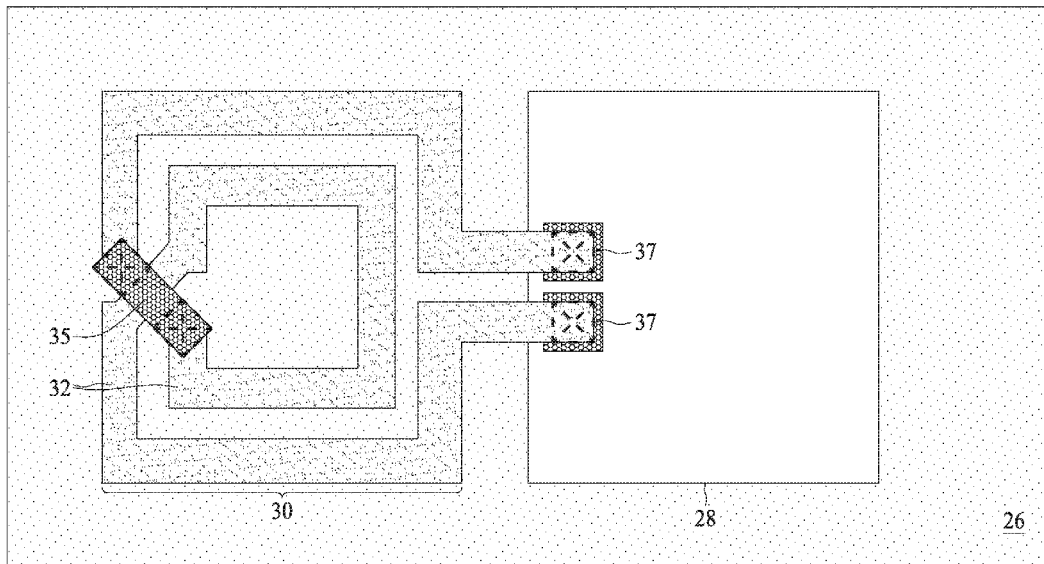
(22) Filed: **Sep. 10, 2018**

A structure includes an encapsulating material, and a coil including a through-conductor. The through-conductor is in the encapsulating material, with a top surface of the through-conductor coplanar with a top surface of the encapsulating material, and a bottom surface of the through-conductor coplanar with a bottom surface of the encapsulating material. A metal plate is underlying the encapsulating material. A slot is in the metal plate and filled with a dielectric material. The slot has a portion overlapped by the coil.

**Related U.S. Application Data**

(63) Continuation of application No. 15/061,419, filed on Mar. 4, 2016, now Pat. No. 10,074,472.

(60) Provisional application No. 62/267,622, filed on Dec. 15, 2015.



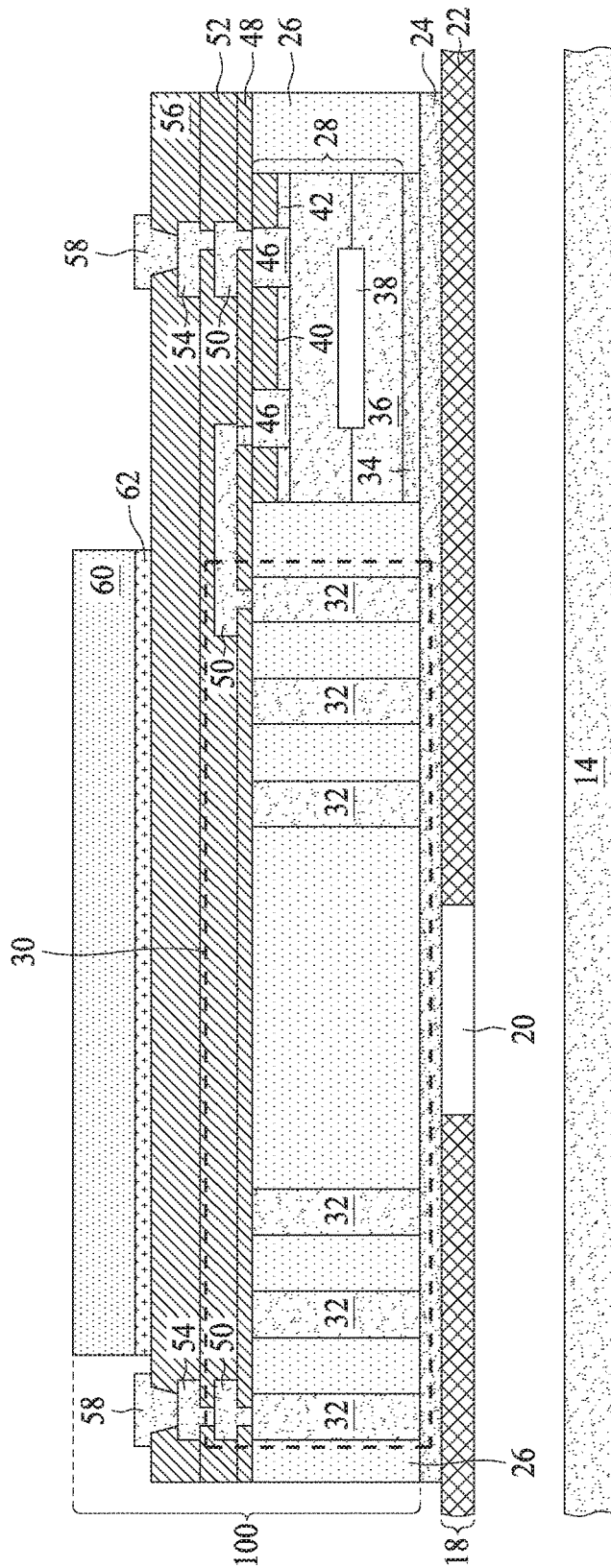


FIG. 1

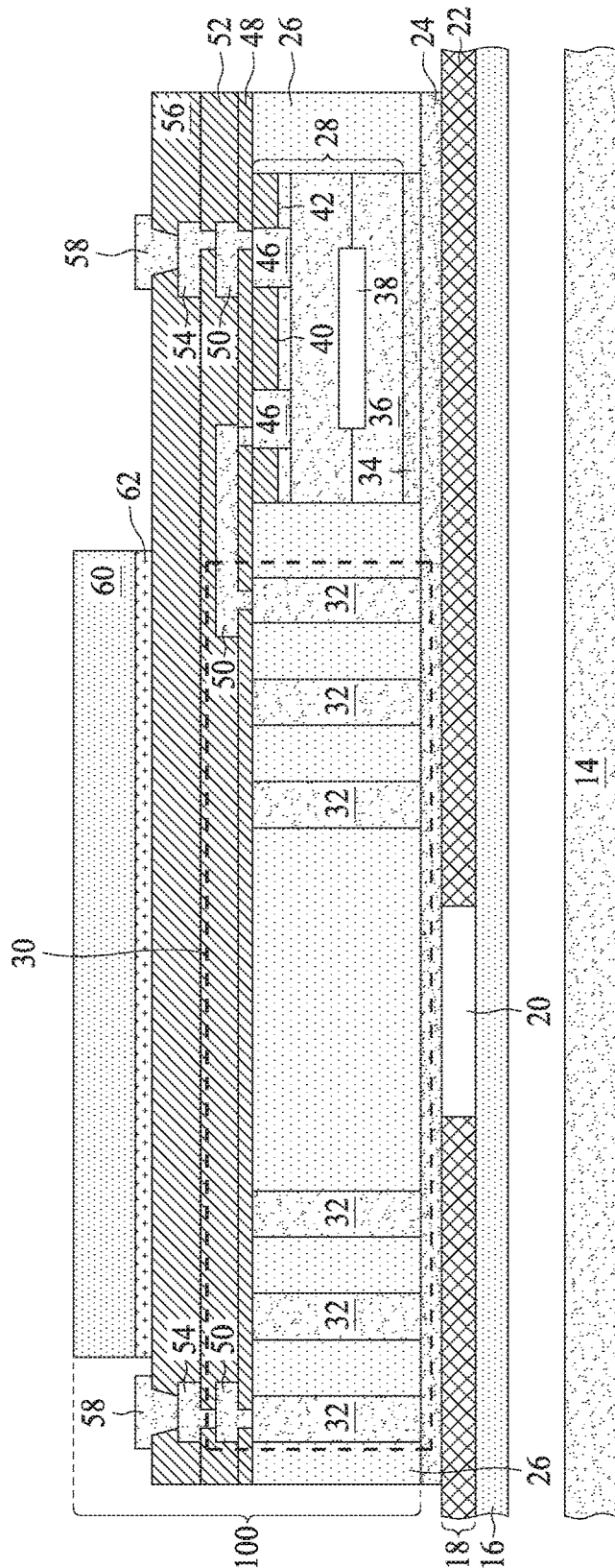


FIG. 2

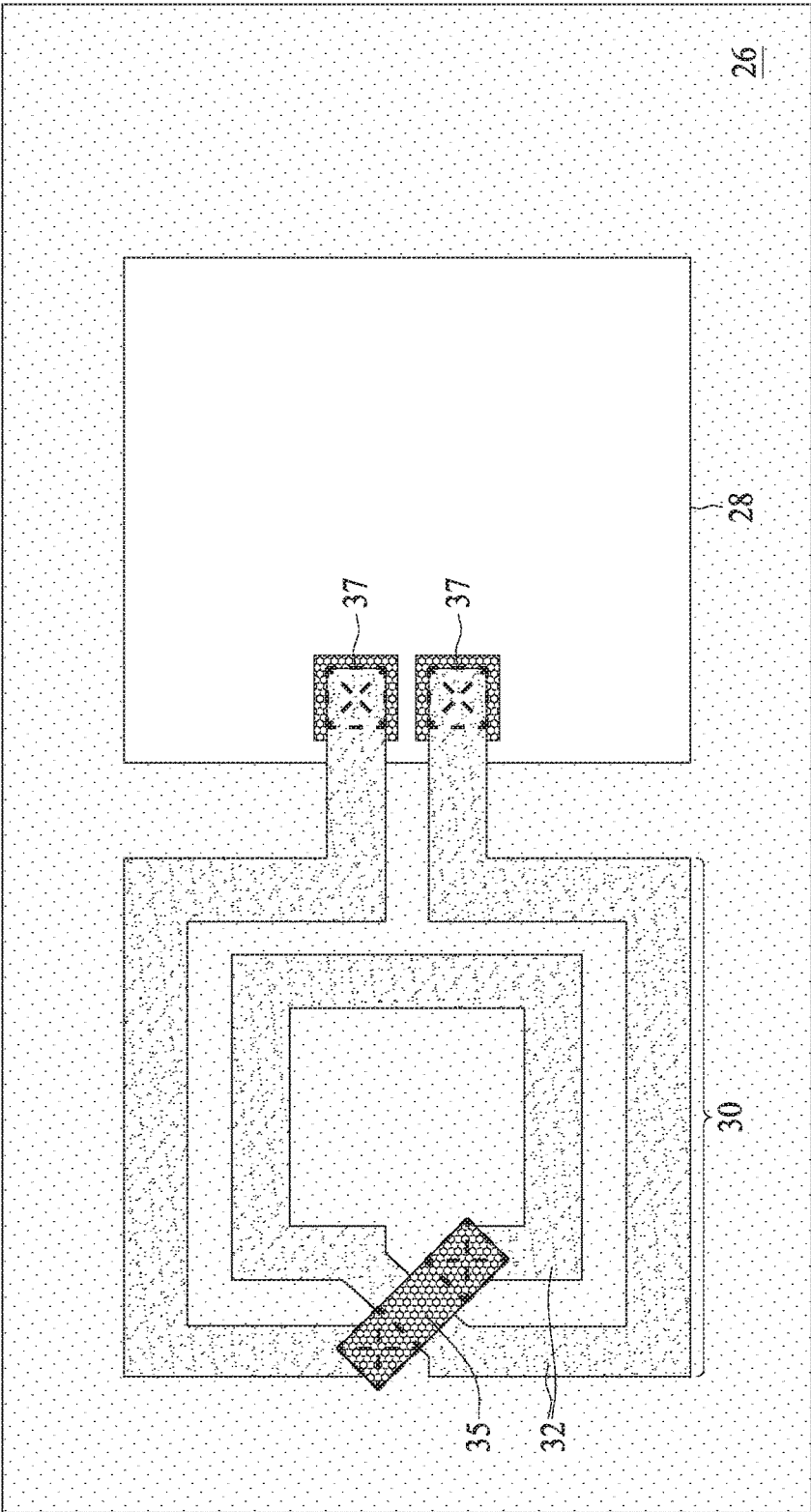


FIG. 3

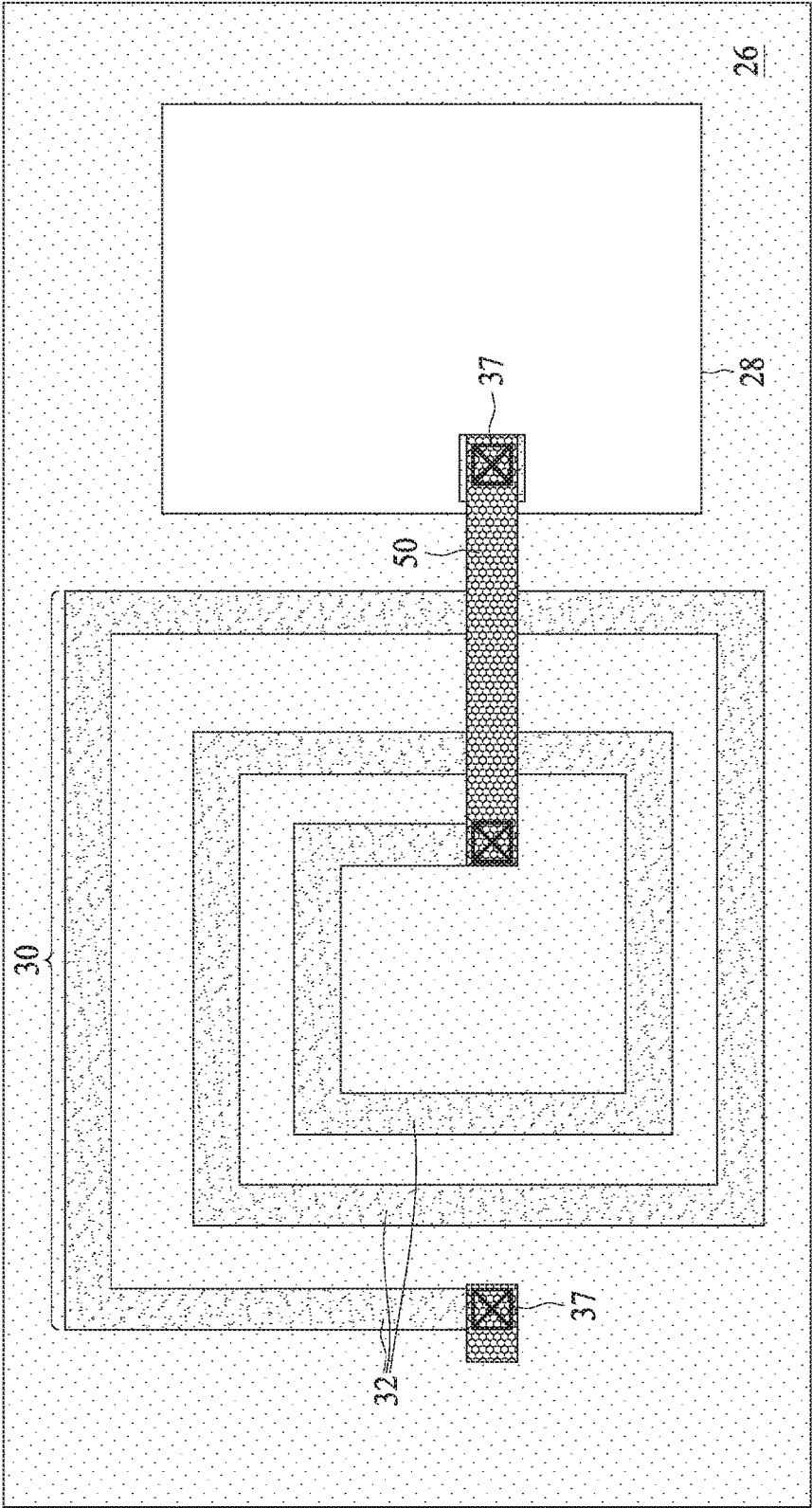


FIG. 4

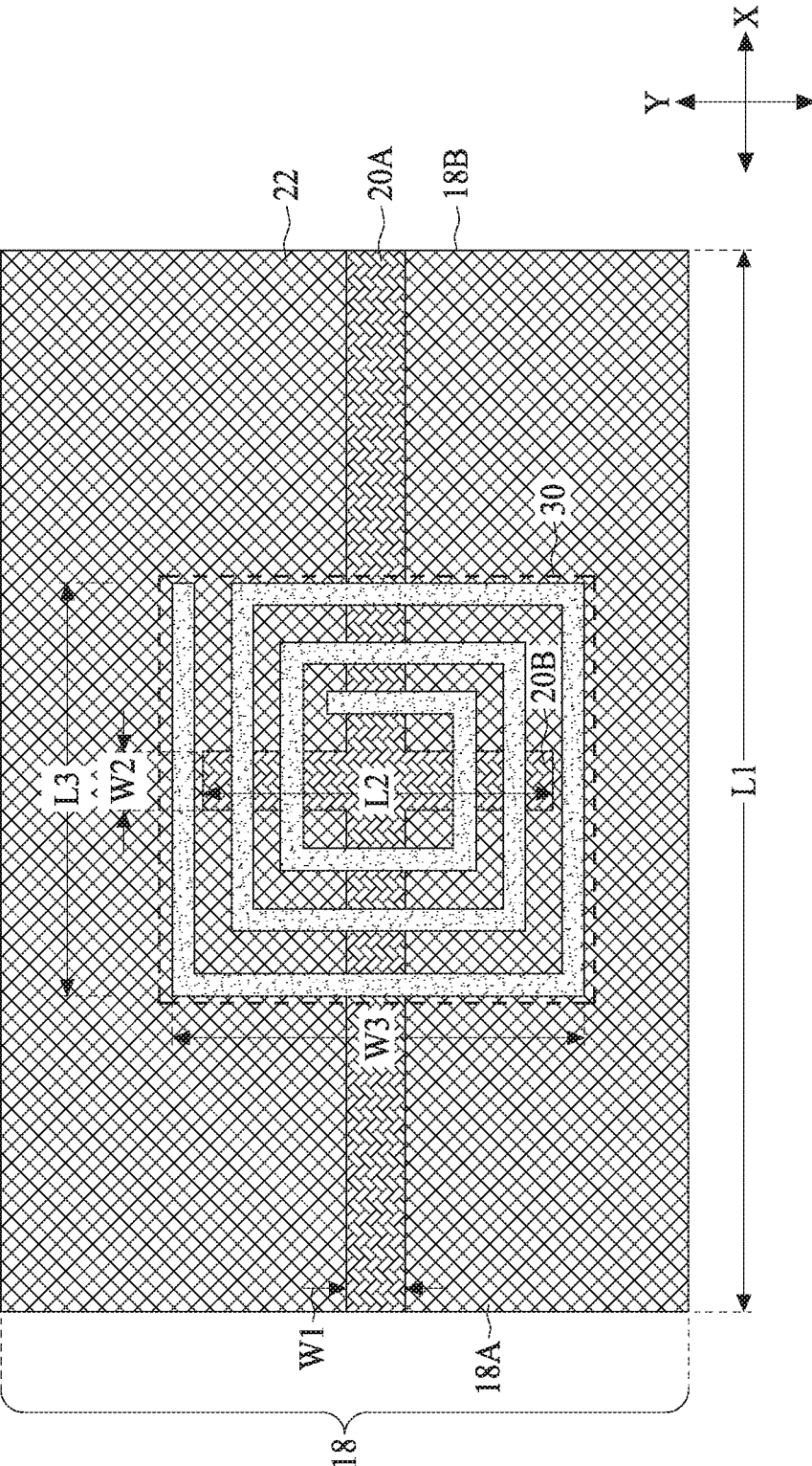


FIG. 5

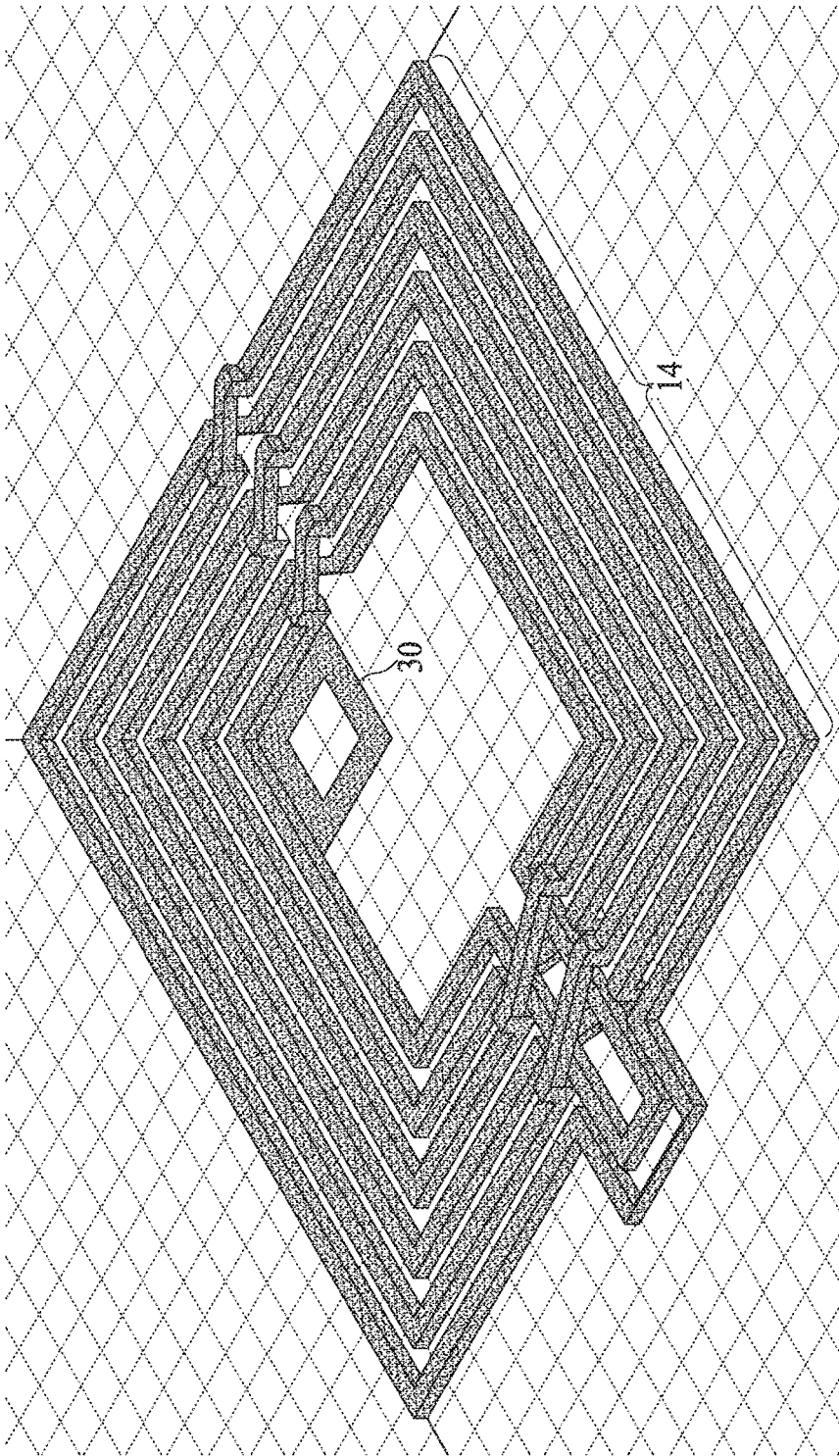


FIG. 6

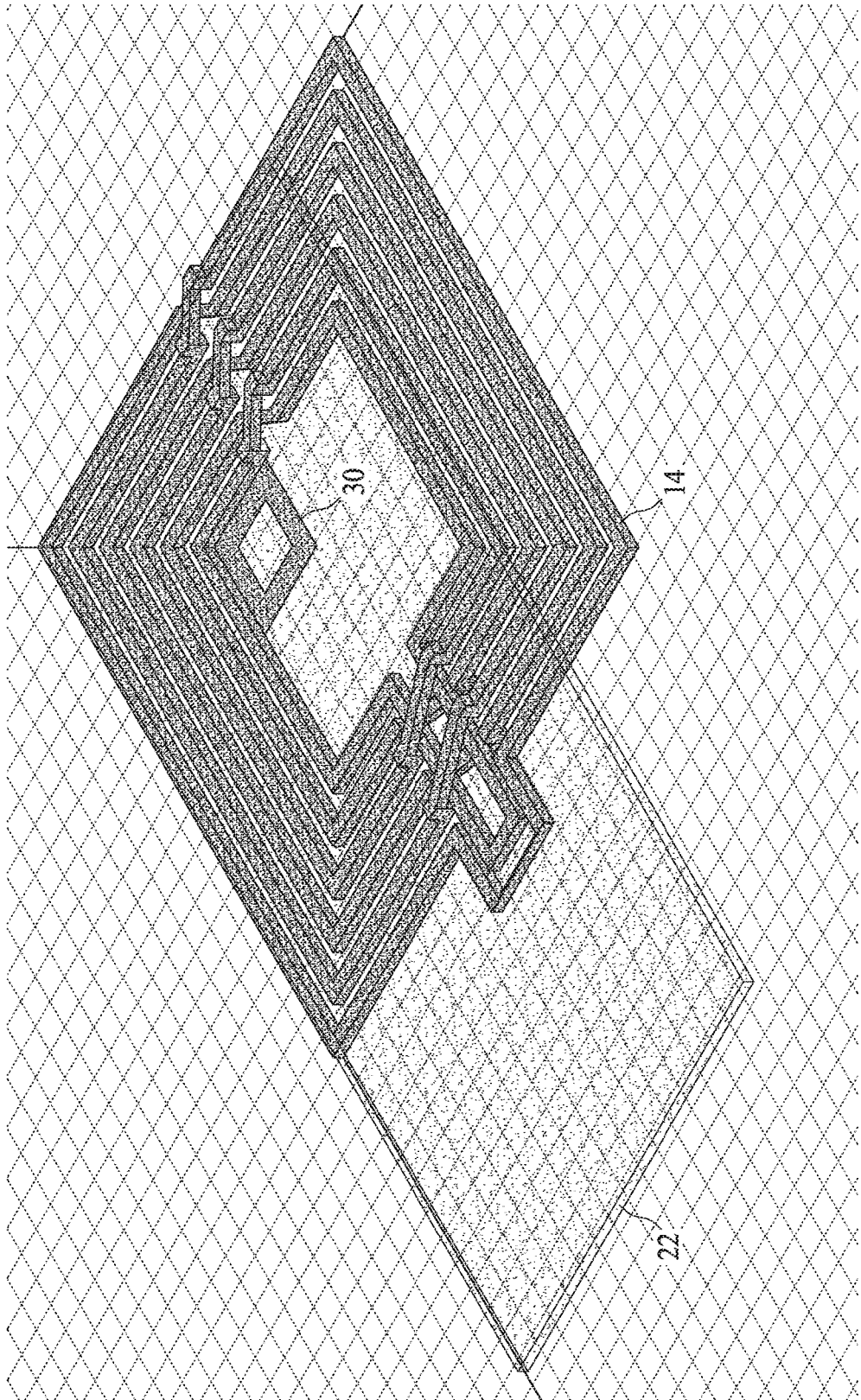


FIG. 7



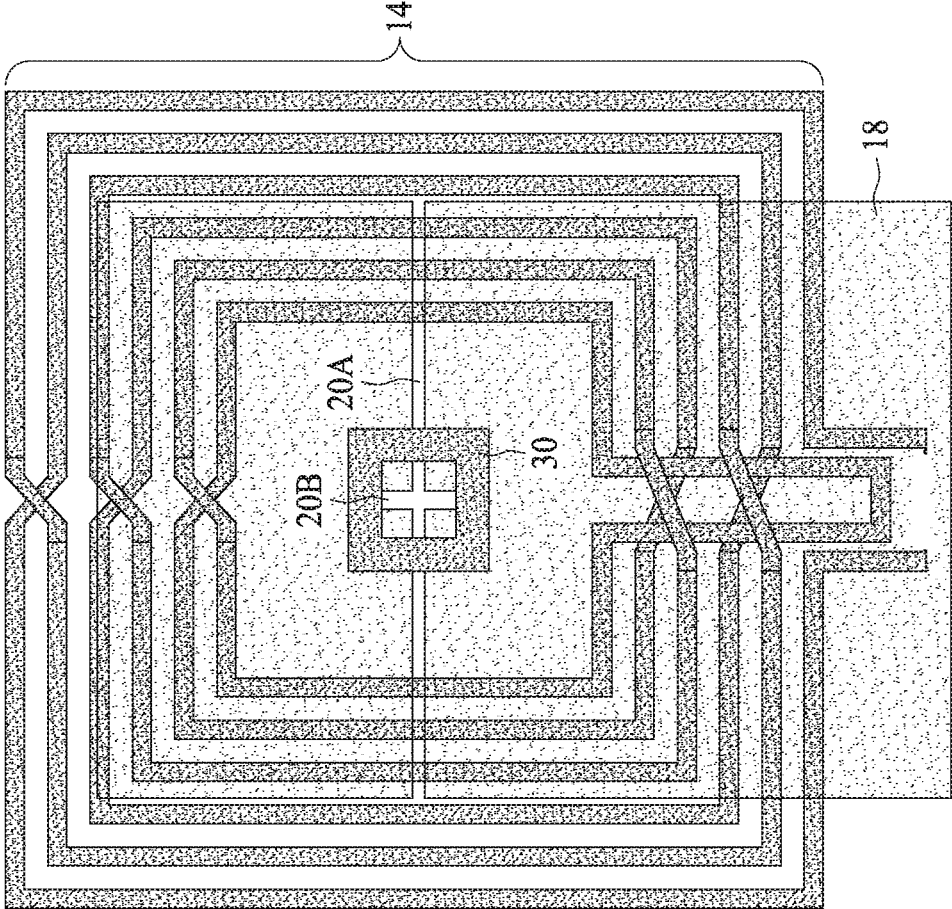


FIG. 8

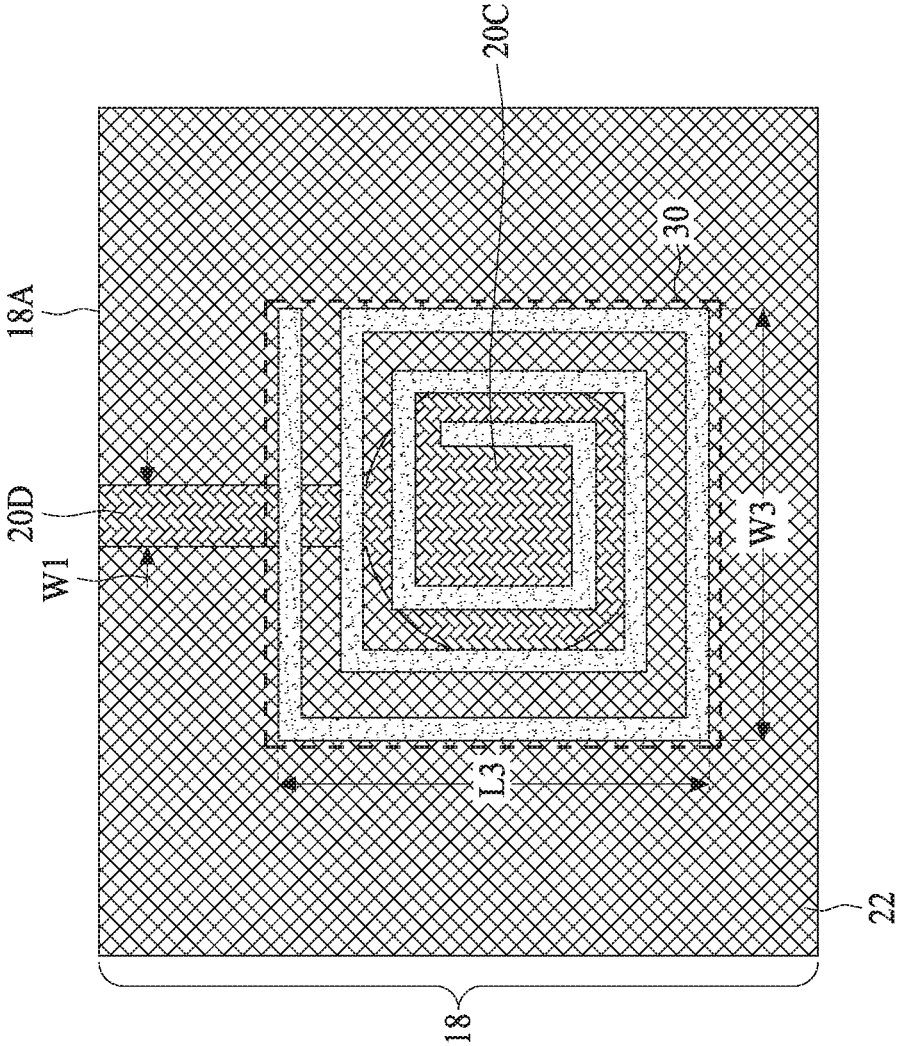


FIG. 9

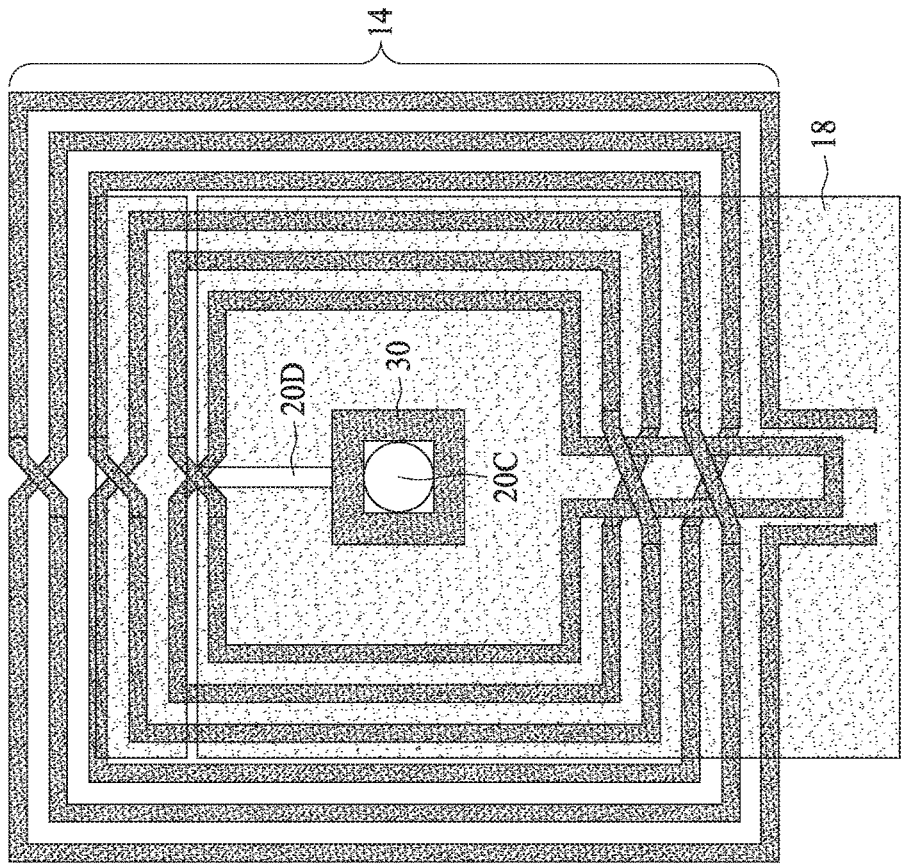


FIG. 10

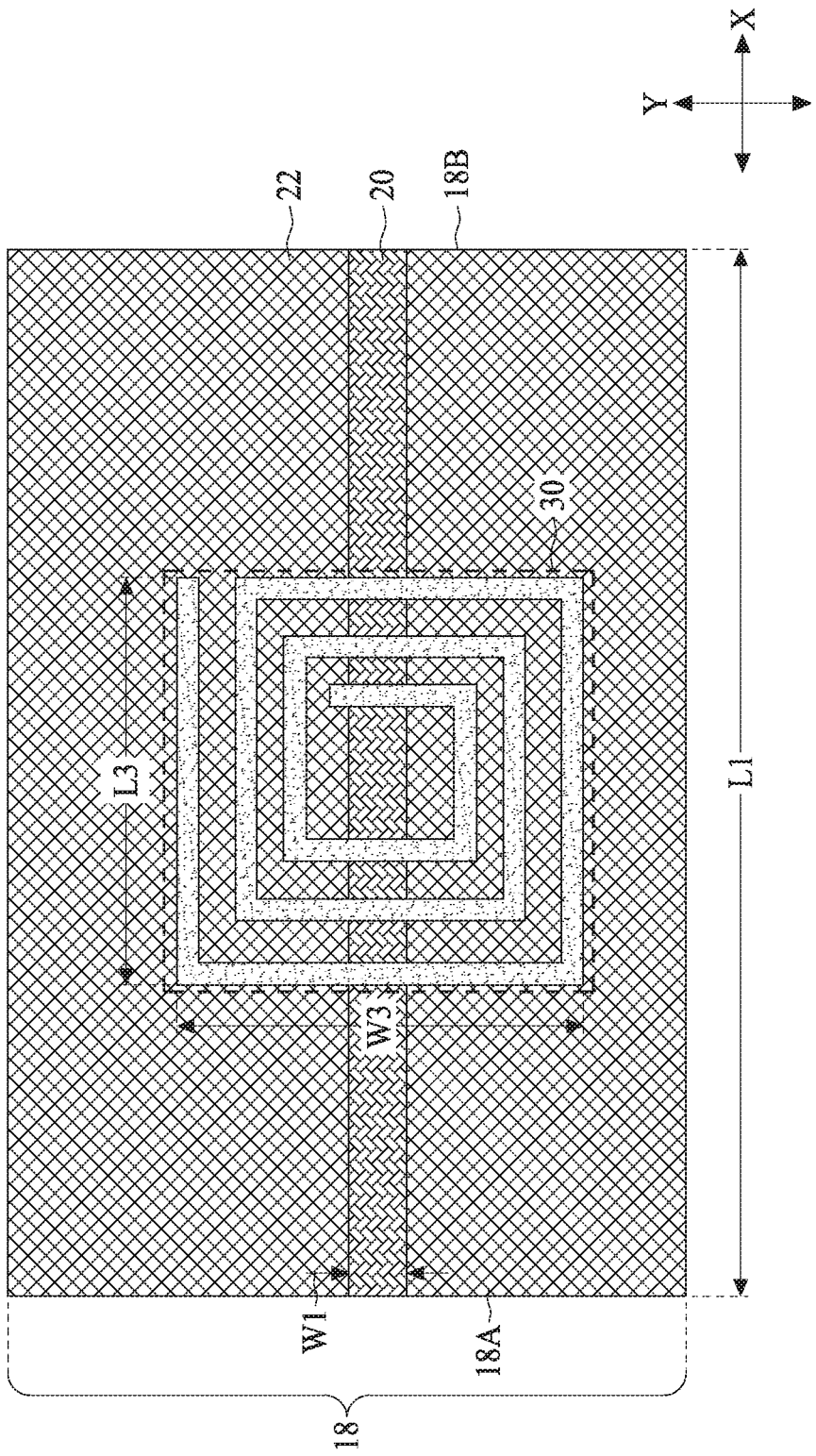


FIG. 11

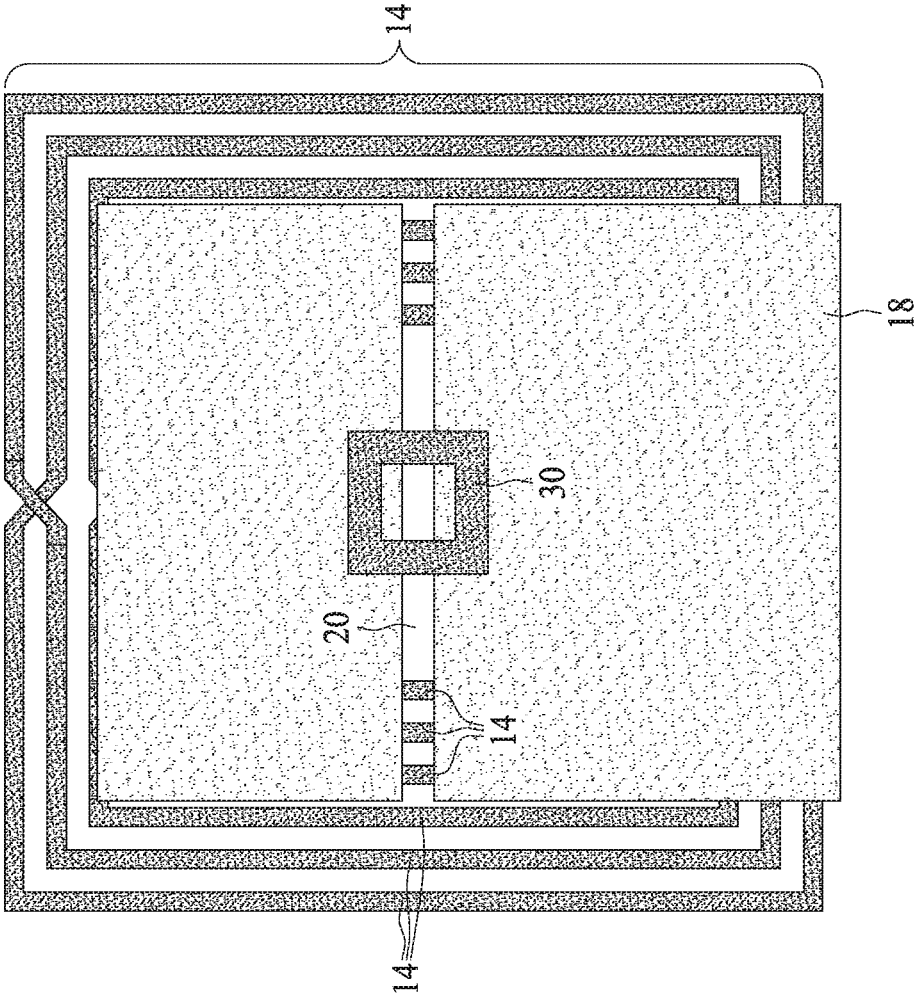


FIG. 12

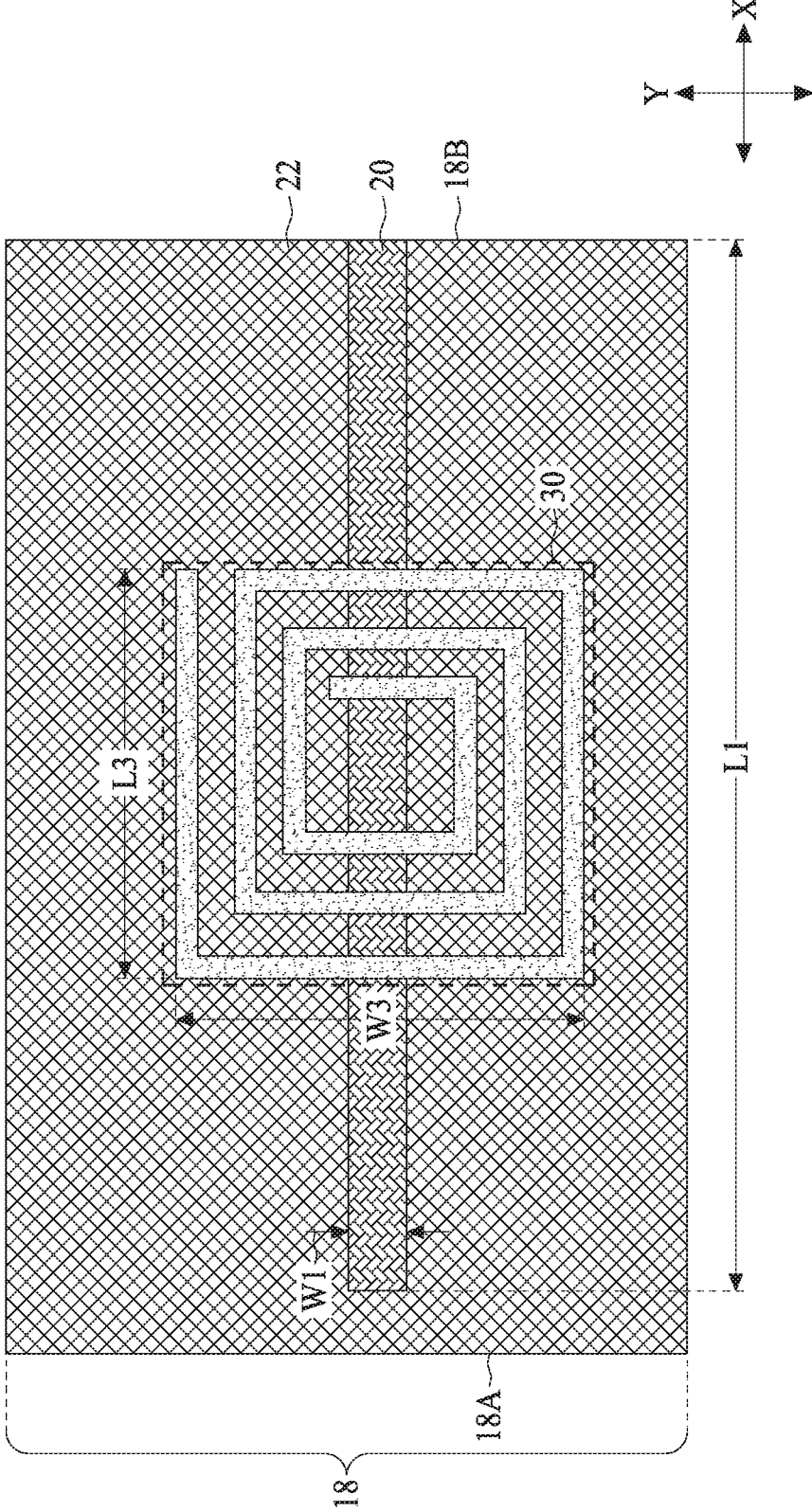


FIG. 13

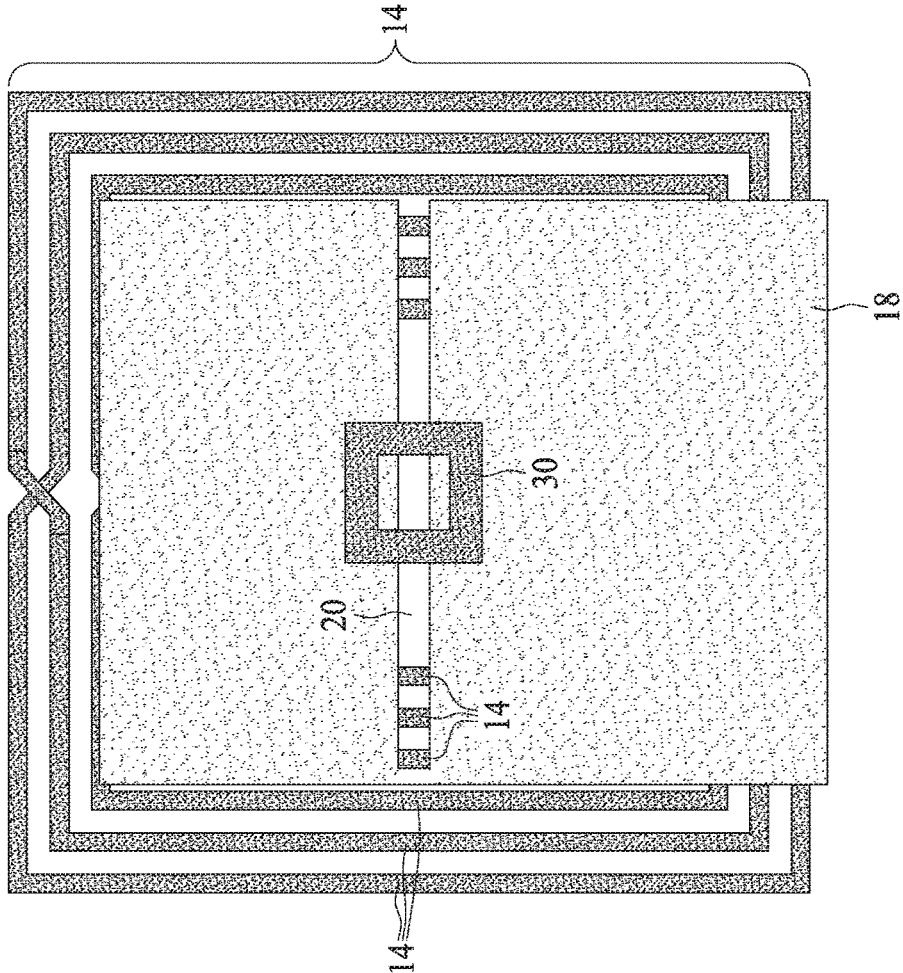


FIG. 14

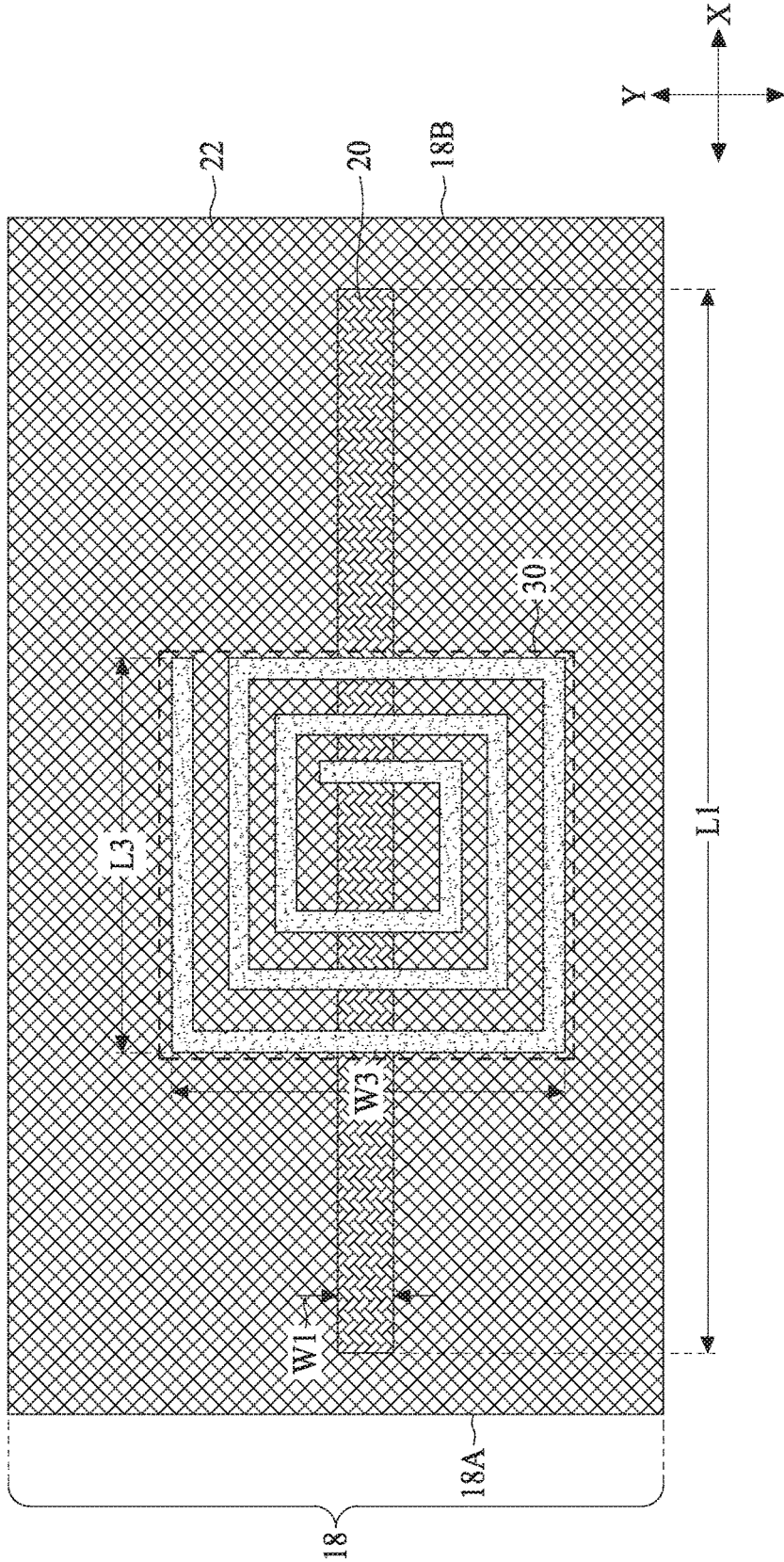


FIG. 15



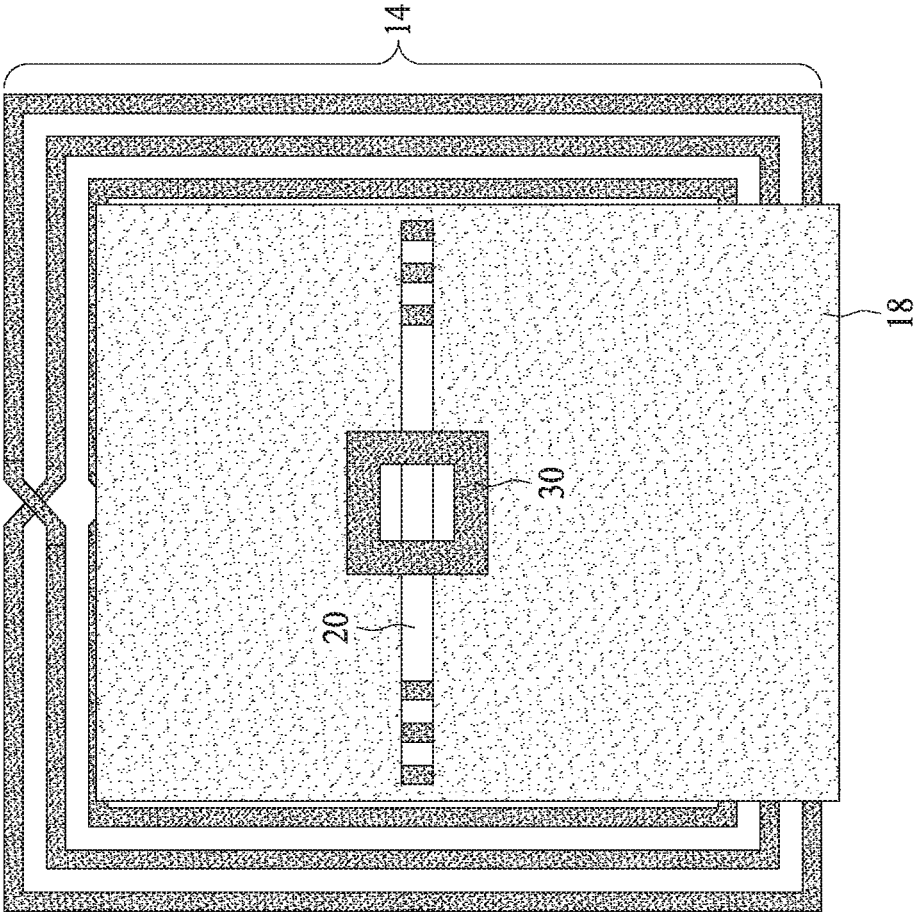


FIG. 16

**INFO COIL ON METAL PLATE WITH SLOT****PRIORITY CLAIM**

[0001] This application is a continuation of U.S. patent application Ser. No. 15/061,419, filed Mar. 4, 2016, and entitled “InFO Coil on Metal Plate With Slot,” which claims the benefit of the following provisionally filed U.S. Patent application: Application Ser. No. 62/267,622, filed Dec. 15, 2015, and entitled “InFO Coil and Performance Improvement Method;” which applications are hereby incorporated herein by reference.

**BACKGROUND**

[0002] With the evolving of semiconductor technologies, semiconductor chips/dies are becoming increasingly smaller. In the meantime, more functions need to be integrated into the semiconductor dies. Accordingly, the semiconductor dies need to have increasingly greater numbers of I/O pads packed into smaller areas, and the density of the I/O pads rises quickly over time. As a result, the packaging of the semiconductor dies becomes more difficult, which adversely affects the yield of the packaging.

[0003] Conventional package technologies can be divided into two categories. In the first category, dies on a wafer are packaged before they are sawed. This packaging technology has some advantageous features, such as a greater throughput and a lower cost. Further, less underfill or molding compound is needed. This packaging technology suffers from drawbacks. For example, the sizes of the dies are becoming increasingly smaller, and the respective packages can only be fan-in type packages, in which the I/O pads of each die are limited to the region directly over the surface of the respective die. With the limited areas of the dies, however, the number of the I/O pads is limited due to the limitation of the pitch of the I/O pads. If the pitch of the pads is to be decreased, solder regions may bridge with each other, causing circuit failure. Additionally, under the fixed ball-size requirement, solder balls must have a certain size, which in turn limits the number of solder balls that can be packed on the surface of a die. Accordingly, Integrated Fan-Out (InFO) packages have been developed.

[0004] InFO packages are not suitable for making coils that are used for certain applications such as wireless charging. Due to the small size of the InFO packages, the coils, if made in the InFO packages, would be small. The mutual inductance between the coils in the InFO packages and the coils outside of the InFO packages will be low, and cannot meet the requirement of wireless power transfer through magnetic resonance. On the other hand, the mutual inductance also cannot be increased by increasing the number of turns of the coils since this will cause the resistance to be increased, which in turn causes the dramatic reduction of the efficiency of the power transfer.

**BRIEF DESCRIPTION OF THE DRAWINGS**

[0005] Aspects of the present disclosure are best understood from the following detailed description when read with the accompanying figures. It is noted that, in accordance with the standard practice in the industry, various features are not drawn to scale. In fact, the dimensions of the various features may be arbitrarily increased or reduced for clarity of discussion.

[0006] FIG. 1 illustrates the cross-sectional view of an Integrated Fan-Out (InFO) package in accordance with some embodiments.

[0007] FIG. 2 illustrates the cross-sectional view of an InFO package including a sealed air gap in accordance with some embodiments.

[0008] FIGS. 3 and 4 illustrate top views of coils and the connecting device dies in accordance with some embodiments.

[0009] FIGS. 5, 9, 11, 13, and 15 illustrate the top views of coils and the respective metal plates and dielectric regions in the metal plates in accordance with some embodiments.

[0010] FIGS. 6-8, 10, 12, 14, and 16 illustrate the structures used for simulations in accordance with some embodiments.

**DETAILED DESCRIPTION**

[0011] The following disclosure provides many different embodiments, or examples, for implementing different features of the invention. Specific examples of components and arrangements are described below to simplify the present disclosure. These are, of course, merely examples and are not intended to be limiting. For example, the formation of a first feature over or on a second feature in the description that follows may include embodiments in which the first and second features are formed in direct contact, and may also include embodiments in which additional features may be formed between the first and second features, such that the first and second features may not be in direct contact. In addition, the present disclosure may repeat reference numerals and/or letters in the various examples. This repetition is for the purpose of simplicity and clarity and does not in itself dictate a relationship between the various embodiments and/or configurations discussed.

[0012] Further, spatially relative terms, such as “underlying,” “below,” “lower,” “overlying,” “upper” and the like, may be used herein for ease of description to describe one element or feature’s relationship to another element(s) or feature(s) as illustrated in the figures. The spatially relative terms are intended to encompass different orientations of the device in use or operation in addition to the orientation depicted in the figures. The apparatus may be otherwise oriented (rotated 90 degrees or at other orientations) and the spatially relative descriptors used herein may likewise be interpreted accordingly.

[0013] An Integrated Fan-Out (InFO) package and a coil in the InFO package are provided in accordance with various exemplary embodiments. The coils in the InFO packages are referred to as InFO coils throughout the description. Some variations of some embodiments are discussed. Throughout the various views and illustrative embodiments, like reference numbers are used to designate like elements.

[0014] FIG. 1 illustrates a cross-sectional view of InFO package 100 in accordance with some embodiments of the present disclosure. InFO package 100 includes device die 28 encapsulated in encapsulating material 26. In addition, through-conductors 32, which form parts of InFO coil 30, are also encapsulated in encapsulating material 26. Encapsulating material 26 fills the gaps between neighboring through-conductors 32 and the gaps between through-conductors 32 and device die 28. Encapsulating material 26 may be a polymer-based material, and may include a molding compound, a molding underfill, an epoxy, and/or a resin. The top surface of encapsulating material 26 is level with the top

ends of device die **28**, which may be achieved through, for example, Chemical Mechanical Polish (CMP).

**[0015]** InFO coil **30** acts as an inductor, and may have various applicable shapes. For example, FIGS. **3** and **4** illustrate the top views of exemplary inductors/coils in accordance with some exemplary embodiments. In FIG. **3**, through-conductors **32** form a plurality of concentric rings, with the outer rings encircling the inner rings. In FIG. **3**, two rings are illustrated, while any other number of rings (such as 1, 3, or more) is also contemplated. The rings are partial rings having breaks, which allow the outer rings to be connected to the inner rings through bridge(s) **35**. The plurality of rings is serially connected to two ports **37**. The ports of coil **30** are connected to device die **28**. In FIG. **4**, through-conductors **32** are portions of an integrated spiral, which also have ports **37**. FIG. **4** illustrates that the left port **37** is disconnected from device die **28**. In alternative embodiments, the left port **37** may also be connected to device die **28**, for example, through the redistribution lines **50** and **54** as shown in FIGS. **1** and **2**.

**[0016]** Referring back to FIG. **1**, through-conductors **32** have top surfaces substantially coplanar with the top surface of encapsulating material **26**, and bottom surfaces substantially coplanar with the bottom surface of encapsulating material **26**. Throughout the description, when the term “substantially coplanar” is used, the respective “planar surfaces” may still have height differences that are within the variation of the respective manufacturing processes.

**[0017]** Device die **28** may be adhered to adhesive film **24** through Die-Attach Film (DAF) **34**, which is an adhesive film. DAF **34** may also be omitted, and device die **28** is adhered to adhesive film **24** directly. Device die **28** may have the function of receiving current from coil **30**, rectifying the current, and charging a battery (not shown). Although one device die **28** is illustrated, more device dies may be placed over adhesive film **24**, which device dies may include a Central Processing Unit (CPU) die, a Micro Control Unit (MCU) die, an Input-output (IO) die, a BaseBand (BB) die, and/or an Application Processor (AP) die.

**[0018]** Device die **28** may include semiconductor substrate **36**, which may be a silicon substrate. Integrated circuit devices **38** are formed on semiconductor substrate **36**. Integrated circuit devices **38** may include active devices such as transistors and diodes and/or passive devices such as resistors, capacitors, inductors, or the like. Device die **28** may include metal pillars **46** electrically coupled to integrated circuit devices **38**. Metal pillars **46** may be embedded in dielectric layer **40**, which may be formed of PBO or polyimide, for example. Passivation layer **42** is also illustrated, wherein metal pillars **46** may extend into passivation layer **42**. Passivation layer **42** may include silicon nitride, silicon oxide, or multi-layers thereof.

**[0019]** Dielectric layer **48** is formed over encapsulating material **26**. In accordance with some embodiments of the present disclosure, dielectric layer **48** is formed of a polymer such as PBO, polyimide, or the like. In accordance with alternative embodiments of the present disclosure, dielectric layer **48** is formed of an inorganic material such as silicon nitride, silicon oxide, or the like.

**[0020]** Redistribution Lines (RDLs) **50** are formed to electrically couple to metal pillars **46** and through-conductors **32**. RDLs **50** may also interconnect metal pillars **46** and through-conductors **32**. In addition, RDLs **50** may be used to form bridge **35** (FIG. **3**) of inductor **30**. RDLs **50** include

metal traces (metal lines) over dielectric layer **48** and vias extending into dielectric layer **48**. The vias in RDLs **50** are connected to through-conductors **32** and metal pillars **46**. In accordance with some embodiments of the present disclosure, the formation of RDLs **50** includes forming a blanket copper seed layer, forming and patterning a mask layer over the blanket copper seed layer, performing a plating to form RDLs **50**, removing the mask layer, and etching the portions of the blanket copper seed layer not covered by RDLs **50**. RDLs **50** may be formed of a metal or a metal alloy including aluminum, copper, nickel, tungsten, and/or alloys thereof.

**[0021]** Dielectric layer **52** is formed over dielectric layer **48** and RDLs **50**. Dielectric layer **52** may be formed using a material selected from the same candidate materials for forming dielectric layer **48**. RDLs **54** are formed to have some portion inside dielectric layer **52**, and some other portions over dielectric layer **52**. RDLs **54** may also be formed of a metal or a metal alloy including aluminum, copper, tungsten, and/or alloys thereof. It is appreciated that although in the illustrated exemplary embodiments, two layers of RDLs (**50** and **54**) are formed, the RDLs may have any number of layers such as one layer or more than two layers.

**[0022]** Dielectric layer **56** is formed over dielectric layer **52** and RDLs **54**. Dielectric layer **56** may be formed, for example, using PBO, polyimide, or BCB. Electrical connectors **58** have some portion inside dielectric layer **56**, and some other portions over dielectric layer **56**. Electrical connectors **58** are formed to electrically connect to RDLs **54**. Electrical connectors **58** may include Under-Bump Metallurgies (UBMs), metal pillars, solder regions, and/or the like. In accordance with some exemplary embodiments, electrical connectors **58** are electrically connected to a flex Printed Circuit Board (PCB, not shown).

**[0023]** In accordance with some embodiments, ferrite material **60**, which may be a pre-formed plate, is adhered to a top surface layer such as layer **56**. The adhesion may be achieved through adhesive film **62**. Ferrite material **60** in accordance with some embodiments may include manganese-zinc, nickel-zinc, or the like. Ferrite material **60** has low losses at high frequencies, and is used to improve the performance (such as the mutual inductance) of InFO coil **30**. Ferrite material **60** overlaps a portion of the encapsulating material **26**. Furthermore, ferrite material **60** overlaps at least a part of InFO coil **30**, and may or may not extend beyond the edges of InFO coil **30**.

**[0024]** Throughout the description of the present disclosure, the features over adhesive film **24** including electrical connectors **58**, device die **28**, encapsulating material **26**, and through-conductors **32** are in combination referred to as InFO package **100**. Slot-containing metal plate **18** is underlying, and is overlapped by, InFO package **100**. In accordance with some embodiments of the present disclosure, InFO package **100** is adhered to slot-containing metal plate **18** through adhesive film **24**.

**[0025]** Slot-containing metal plate **18** includes metal plate **22**, and dielectric material **20** in the slot of metal plate **22**. Throughout the description, reference numeral **20** is used to refer to both the slots in slot-containing metal plate **18** and the dielectric material in the slots. In accordance with some embodiments of the present disclosure, metal plate **22** is formed of a metal or a metal alloy, which is formed of copper, aluminum, nickel, chromium, an anodized metal,

and/or the like. Dielectric material **20** may fully or partially fill the slot in metal plate **22**. In accordance with some embodiments, dielectric material **20** is formed of an organic material such as plastic or polymer, or an inorganic dielectric material such as glass, oxide, ceramic, or the like. Dielectric material **20** may be transparent or opaque.

**[0026]** Metal plate **22** and dielectric material **20** may have top surfaces substantially coplanar with each other, and/or bottom surfaces coplanar with each other. In accordance with some embodiments of the present disclosure, metal plate **22** and dielectric material **20** in combination form a part of a casing, which may be the casing of a mobile phone, a tablet, or a computer, for example. The illustrated portion of the casing is a lower part, and the casing may further include an upper part overlying, and portions (not shown) on the left side and right of, the illustrated part.

**[0027]** FIG. 2 illustrates InFO package **100** and slot-containing metal plate **18** in accordance with alternative embodiments. Slot-containing metal plate **18** includes slot **20** therein, wherein slot **20** is an air gap not filled with solid dielectric materials. Alternatively stated, slot **20** is filled with air, and hence forming a dielectric region. Dielectric film **16** is used to cover slot **20**, wherein dielectric film **16** and adhesive **24** seal slot **20**. Throughout the description, when the term “dielectric material **20**” is referred to, it indicates that dielectric material **20** may be a solid dielectric material or air. Dielectric film **16** may also be formed of a dielectric material such as a plastic, a glass, a ceramic, or the like.

**[0028]** FIG. 5 illustrates a top view of a part of the structure shown in FIGS. 1 and 2 in accordance with some exemplary embodiments, with coil **30** and slot-containing metal plate **18** illustrated. Other materials and regions such as dielectric layers **48**, **52**, and **56**, device die **28**, and the like as shown in FIGS. 1 and 2 are not illustrated, while they still exist. Dielectric material **20** includes portions **20A** and **20B** (referred to as a dielectric portions or slot portions hereinafter). Dielectric portion **20A** has a lengthwise direction parallel to a first direction (X direction). Portion **20B** has a lengthwise direction un-parallel to the lengthwise direction of portion **20A**. In accordance with some embodiments of the present disclosure, the lengthwise direction of portion **20B** is in the Y direction, which is perpendicular to the lengthwise direction of portion **20A**. Portions **20A** and **20B** may also be neither parallel to nor perpendicular to each other. Furthermore, portion **20A** may be longer than portion **20B**. Portion **20A** and portion **20B** are joined with each other to form a cross.

**[0029]** In accordance with some embodiments, slot-containing metal plate **18** has edges **18A** and **18B** opposite to each other. Edges **18A** and **18B** may or may not be parallel to each other, depending on the shape and the usage of slot-containing metal plate **18**. For example, when slot-containing metal plate **18** is used as the back cover of a mobile phone, the shape of slot-containing metal plate **18** is determined by the shape of the mobile phone, and edges **18A** and **18B** may be parallel to each other. Slot portion **20A** has length  $L1$  and width  $W1$ . Length  $L1$  in accordance with these embodiments is greater than length  $L3$  of coil **30**, and is equal to the length of slot-containing metal plate **18**. Width  $W1$  of slot portion **20A** is smaller than length  $L1$ , and may be smaller than the width  $W3$  of coil **30**.

**[0030]** Portion **20B** of dielectric material **20** has length  $L2$  and width  $W2$  smaller than length  $L2$ . Furthermore, width  $W2$  may be equal to, greater than, or smaller than, width  $W1$

of portion **20A**. In accordance with some embodiments of the present application, length  $L2$  of portion **20B** is smaller than width  $W3$  of coil **30**, and width  $W2$  of portion **20B** is smaller than both length  $L3$  and width  $W3$  of coil **30**.

**[0031]** Furthermore, portion **20A** may extend beyond the edges of coil **30** in opposite X directions. On the other hand, portion **20B** may be fully in the region overlapped by coil **30**, and does not extend beyond the edges of coil **30** (as shown in FIG. 5). Alternatively, portion **20B** may also extend beyond the edges of coil **30** in one or both of the Y directions. In accordance with some exemplary embodiments, the intersection area of portions **20A** and **20B** is aligned to coil **30**. The center of the intersection area may be aligned to the center of coil **30** to maximize the magnification effect, as is discussed in subsequent paragraphs.

**[0032]** The InFO coil **30** as shown in FIG. 5 has improved mutual inductance with an external coil **14** (FIG. 1 or 2). As shown in FIGS. 1 and 2, coil **14** is placed outside of InFO package **100**, and may be outside of the product (such as a mobile phone) in which InFO package **100** is located. Coil **14** may be used as a transmitter coil for transmitting energy, for example, while InFO coil **30** is used as a receiver coil for receiving the energy transmitted by coil **14**.

**[0033]** FIGS. 6, 7, and 8 illustrate the structures on which simulations are performed. FIG. 6 illustrates the perspective view of coil **14** and coil **30**. InFO coil **30** is over coil **14**, with no metal plate between InFO coil **30** and coil **14**. Furthermore, InFO coil **30** is above coil **14**, and the center of coil **30** is aligned to the center of coil **14**. According to the simulation results, the mutual inductance between InFO coil **30** and coil **14** is 123.6 nH. In this setting, the electromagnetic field generated by coil **14** is transmitted to InFO coil **30** without being blocked.

**[0034]** FIG. 7 illustrates the perspective view of coil **14** and coil **30**, on which a simulation is performed. InFO coil **30** is over and aligned to coil **14**, with a large metal plate **22** between (and aligned to) InFO coil **30** and coil **14**. Metal plate **22** has no slot therein, and hence fully blocks the electromagnetic field generated by coil **14** from being transmitted to coil **30**. According to the simulation results, the mutual inductance between InFO coil **30** and coil **14** is 0.1 nH, indicating that essentially no mutual inductance exists between InFO coil **30** and coil **14**. Accordingly, InFO coil **30** and coil **14** cannot be used for wireless power transfer when an un-slotted metal plate (such as an un-slotted metal back cover of a phone) is placed therebetween. The results obtained from FIGS. 6 and 7 are used as benchmarks to compare the performance of other structures in accordance with various embodiments of the present disclosure.

**[0035]** FIG. 8 illustrates the top view of coil **14** and coil **30**, on which a simulation is performed. InFO coil **30** is over coil **14**, with slot-containing metal plate **18** (same as what is shown in FIG. 5) placed between InFO coil **30** and coil **14**. According to the simulation results, the mutual inductance between InFO coil **30** and coil **14** is 192 nH. It is noted that this mutual inductance is greater than the mutual inductance obtained from FIG. 6 (123.6 nH). This indicates that the cross-shaped slot as shown in FIG. 5 not only allows the full passing-through of the electromagnetic field, the electromagnetic field is also magnified, which means better efficiency in the wireless charging.

**[0036]** Referring again back to FIG. 5, if the widths  $W1$  and/or  $W2$  of slot **20** are too big, for example, equal to or greater than width  $W3$  of coil **30**, the mutual inductance

would be reduce to the mutual inductance (123.6 nH) obtained from FIG. 6. Accordingly, keeping widths W1 and/or W2 not too big is beneficial for increasing the mutual inductance. On the other hand, widths W1 and/or W2 cannot be too small since the slots with very small widths W1 and/or W2 do not allow the electromagnetic field to pass easily, and the mutual inductance may degrade to the mutual inductance obtained in FIG. 7. In accordance with some embodiments, widths W1 and/or W2 are equal to or greater than the wavelength of the power applied on coil 14.

[0037] FIG. 9 illustrates a top view of a part of the structure shown in FIGS. 1 and 2 in accordance with some exemplary embodiments, with coil 30 and slot-containing metal plate 18 illustrated. Dielectric material 20 includes central bulk portion 20C and elongated portion 20D, which is joined to bulk portion 20C to form a continuous dielectric region. Bulk portion 20C is overlapped by coil 30 (when viewed in the cross-sectional view). In accordance with some exemplary embodiments, bulk portion 20C is smaller (in the top view as in FIG. 6) than coil 30. Furthermore, all edges of bulk portion 20C may be rescinded from the respective edges of coil 30, and hence coil 30 fully overlaps bulk portion 20C. Alternatively stated, coil 30 extends beyond the edges of bulk portion 20C. In accordance with some exemplary embodiments, the center of the intersection area of portions 20A and 20B is aligned to the center of coil 30. The top view of coil 30 may have a circular shape, a rectangular shape, a hexagonal shape, an octagonal shape, or another applicable shape.

[0038] Elongated portion 20D has a first end connected to bulk portion 20C, and a second end extending beyond the respective edge (the illustrated upper edge) of coil 14. In accordance with some embodiments, as illustrated in FIG. 9, elongated portion 20D extends to edge 18A of slot-containing metal plate 18. In accordance with alternative embodiments, elongated portion 20D extends beyond the respective edge (the illustrated upper edge) of coil 14, and does not reach edge 18A. Width W1 of elongated portion is smaller than width W3 of coil 30 in accordance with some embodiments.

[0039] FIG. 10 illustrates the top view of coil 14 and coil 30, on which a simulation is performed. InFo coil 30 is over coil 14, with slot-containing metal plate 18 (similar to what is shown in FIG. 9, and with an additional slot) placed between InFo coil 30 and coil 14. According to the simulation results, the mutual inductance between InFo coil 30 and coil 14 is 240.4 nH. The results are similar if the additional slot is not added. It is noted that this mutual inductance is greater than the mutual inductance obtained from FIG. 6 (123.6 nH). This indicates that the slot as shown in FIG. 9 has the effect of magnifying the electromagnetic field, which means better efficiency in the wireless charging.

[0040] Referring again back to FIG. 9, if portion 20C is too large, for example, with sizes equal to or greater than the size of coil 30, the mutual inductance would be close to the mutual inductance obtained from FIG. 6. Accordingly, keeping the size of portion 20C to be smaller than the size of coil 30 is beneficial for increasing mutual inductance.

[0041] FIG. 11 illustrates a top view of a part of the structure shown in FIGS. 1 and 2 in accordance with some exemplary embodiments, with coil 30 and slot-containing metal plate 18 illustrated. The shape of dielectric material 20 in accordance with these embodiments is similar to that in FIG. 5, except no shorter portion exists. Dielectric material

20 extends to both edges 18A and 18B of slot-containing metal plate 18. Dielectric material 20 is in a single stripe-shaped slot, which extends from edge 18A to opposite edge 18B of slot-containing metal plate 18. Dielectric material 20 extends beyond the edges of coil 30 in opposite X directions, and length L1 of dielectric material 20 is greater than length L3 of coil 30. On the other hand, width W1 of dielectric material 20 is smaller than width W3 of coil 30.

[0042] FIG. 12 illustrates the top view of coil 14 and coil 30, on which a simulation is performed. InFo coil 30 is over coil 14, with slot-containing metal plate 18 as shown in FIG. 11 placed between InFo coil 30 and coil 14. According to the simulation results, the mutual inductance between InFo coil 30 and coil 14 is 137.9 nH. It is noted that this mutual inductance is greater than the mutual inductance obtained from FIG. 6 (123.6 nH). This indicates that the slot as shown in FIG. 11 also has the effect of magnifying the electromagnetic field, which means better efficiency in the wireless charging.

[0043] Referring again back to FIG. 11, if width W1 of dielectric material 20 is too large, for example, greater than width W3 of coil 30, the mutual inductance would be reduced to the mutual inductance obtained from FIG. 6. Accordingly, keeping width W1 to be smaller than width W3 of coil 30 is beneficial for increasing the mutual inductance. On the other hand, width W1 cannot be too small since the slots with very small width W1 do not allow the electromagnetic field to pass easily, and the mutual inductance may degrade to the mutual inductance obtained in FIG. 7.

[0044] FIG. 13 illustrates a top view of a part of the structure shown in FIGS. 1 and 2 in accordance with some exemplary embodiments, with coil 30 and slot-containing metal plate 18 illustrated. The shape of dielectric material 20 in accordance with these embodiments is similar to that in FIG. 11, except dielectric material 20 extends to edge 18B and does not extend to edge 18A. Similarly, dielectric material 20 extends beyond the edges of coil 30 in both X directions, and length L1 of dielectric material 20 is greater than length L3 of coil 30. On the other hand, width W1 of dielectric material 20 is smaller than width W3 of coil 30.

[0045] FIG. 14 illustrates the top view of coil 14 and coil 30, on which a simulation is performed. InFo coil 30 is over coil 14, with slot-containing metal plate 18 as shown in FIG. 13 placed between InFo coil 30 and coil 14. According to the simulation results, the mutual inductance between InFo coil 30 and coil 14 is 138.2 nH. It is noted that this mutual inductance is greater than the mutual inductance obtained from FIG. 6 (123.6 nH). This indicates that the slot as shown in FIG. 13 has the effect of magnifying the electromagnetic field, which means better efficiency in the wireless charging. The width W1 and length L1 of dielectric material 20 have similar requirement as in FIG. 11.

[0046] FIG. 15 illustrates a top view of a part of the structure shown in FIGS. 1 and 2, with coil 30 and slot-containing metal plate 18 illustrated in accordance with some exemplary embodiments. The shape of dielectric material 20 in accordance with these embodiments is similar to that in FIG. 11, except dielectric material 20 is fully encircled by metal plate 18, and does not extend to either one of edges 18A and 18B. Similarly, dielectric material 20 extends beyond the edges of coil 30 in both X directions, and length L1 of dielectric material 20 is greater than length L3 of coil 30. On the other hand, width W1 of dielectric material 20 is smaller than width W3 of coil 30.

[0047] FIG. 16 illustrates the top view of coil 14 and coil 30, on which a simulation is performed. InFo coil 30 is over coil 14, with slot-containing metal plate 18 as shown in FIG. 15 placed between InFo coil 30 and coil 14. According to the simulation results, the mutual inductance between InFo coil 30 and coil 14 is 29.8 nH. It is noted that this mutual inductance is smaller than the mutual inductance obtained from FIG. 6 (123.6 nH). This indicates that the slot as shown in FIG. 13 allows the electromagnetic field to pass through, although with reduced magnitude. Further comparing the results in FIGS. 8, 10, 12, 14, and 16, it is observed that allowing the dielectric material (slot) in the metal plate to extend to an edge of the metal plate may lead to improved mutual inductance, while not allowing the dielectric material (slot) to reach the edges results in degraded mutual inductance.

[0048] The embodiments of the present disclosure have some advantageous features. By forming slot(s) in metal plates, electromagnetic field may pass through the metal plate, and the mutual inductance between the InFO coil and an external coil is improved. Furthermore, the mutual inductance may be magnified, resulting in the improvement in wireless charging efficiency.

[0049] In accordance with some embodiments of the present disclosure, a structure includes an encapsulating material, and a coil including a through-conductor. The through-conductor is in the encapsulating material, with a top surface of the through-conductor substantially coplanar with a top surface of the encapsulating material, and a bottom surface of the through-conductor substantially coplanar with a bottom surface of the encapsulating material. A metal plate is underlying the encapsulating material. A slot is in the metal plate and filled with a dielectric material. The slot has a portion overlapped by the coil.

[0050] In accordance with some embodiments of the present disclosure, a structure includes an encapsulating material, a device die encapsulated in the encapsulating material, and through-conductors encapsulated in the encapsulating material. The through-conductors form parts of a coil electrically coupled to the device die. The structure further includes a metal plate with a portion overlapped by the coil, wherein the metal plate extends beyond edges of the coil. A dielectric material penetrates through the metal plate. The dielectric material includes a first elongated portion having a first lengthwise direction parallel to a first direction. The first elongated portion includes a first portion overlapped by the coil, and a second portion un-overlapped by the coil. The dielectric material further includes a second elongated portion having a second lengthwise direction parallel to a second direction, with the second direction unparallel to the first direction. The second elongated portion is joined to the first elongated portion, and is overlapped by the coil.

[0051] In accordance with some embodiments of the present disclosure, a structure includes an encapsulating material, a device die encapsulated in the encapsulating material, and through-conductors encapsulated in the encapsulating material. The through-conductors form parts of a coil electrically coupled to the device die. The structure further includes a metal plate with a portion overlapped by the coil. The metal plate extends beyond edges of the coil. A dielectric region penetrates through the metal plate. The dielectric region includes a bulk portion overlapped by the coil, and an elongated portion connected to the bulk portion. The elongated portion is narrower than the bulk portion. The elongated

portion includes a first portion overlapped by the coil, and a second portion extending beyond an edge of the coil.

[0052] The foregoing outlines features of several embodiments so that those skilled in the art may better understand the aspects of the present disclosure. Those skilled in the art should appreciate that they may readily use the present disclosure as a basis for designing or modifying other processes and structures for carrying out the same purposes and/or achieving the same advantages of the embodiments introduced herein. Those skilled in the art should also realize that such equivalent constructions do not depart from the spirit and scope of the present disclosure, and that they may make various changes, substitutions, and alterations herein without departing from the spirit and scope of the present disclosure.

What is claimed is:

1. A structure comprising:
  - an encapsulating material;
  - a coil comprising a through-conductor, wherein the through-conductor is in the encapsulating material;
  - a metal plate underlying the encapsulating material, wherein the metal plate comprises a first side edge and a second side edge opposite to each other, and the metal plate extends laterally beyond edges of the coil; and
  - a first slot in the metal plate and filled with a dielectric material, wherein the first slot extends from a region directly underlying the coil to the first side edge of the metal plate.
2. The structure of claim 1, wherein the first slot is filled with a tangible dielectric material.
3. The structure of claim 1, wherein the first slot is an air gap.
4. The structure of claim 3, wherein the structure further comprises a dielectric film sealing the first slot with the metal plate, with the dielectric film being on an opposite side of the metal plate than the encapsulating material.
5. The structure of claim 1 further comprising a second slot perpendicular to, and intersecting, the first slot, wherein an entirety of the second slot is overlapped by the coil.
6. The structure of claim 1, wherein the first slot further extends to the second side edge of the metal plate.
7. The structure of claim 1 further comprising a dielectric film between and contacting the metal plate and the encapsulating material.
8. The structure of claim 1, wherein the first slot comprises:
  - a bulk portion fully overlapped by the coil; and
  - an elongated portion connected to the bulk portion, wherein the elongated portion has a width smaller than a respective width of the coil and a respective width of the bulk portion, and the elongated portion extends beyond a respective edge of the coil.
9. A structure comprising:
  - an encapsulating material;
  - a device die encapsulated in the encapsulating material;
  - through-conductors encapsulated in the encapsulating material, wherein the through-conductors form parts of a coil, and the coil is electrically coupled to the device die;
  - a metal plate having a portion overlapped by the coil, wherein the metal plate extends beyond edges of the coil; and
  - a dielectric material penetrating through the metal plate, wherein the dielectric material comprises:

- a first elongated portion having a first lengthwise direction parallel to a first direction, wherein the first elongated portion extends to a first edge of the metal plate; and
- a second elongated portion having a second lengthwise direction parallel to a second direction, with the second direction un-parallel to the first direction, wherein the second elongated portion has an end spaced apart from a respective nearest edge of the metal plate.
- 10.** The structure of claim **9**, wherein the metal plate further extends beyond opposite edges of the device die.
- 11.** The structure of claim **9**, wherein the first elongated portion further extends to a second edge of the metal plate, with the first edge and the second edge being opposite edges of the metal plate.
- 12.** The structure of claim **9**, wherein the first elongated portion is spaced apart from a second edge of the metal plate, with the first edge and the second edge being opposite edges of the metal plate.
- 13.** The structure of claim **9**, wherein the first elongated portion has a width measured in the second direction, and the width of the first elongated portion is smaller than a respective dimension of the coil measured in the second direction.
- 14.** The structure of claim **9**, wherein the second elongated portion is joined to the first elongated portion, and an entirety of the second elongated portion is overlapped by the coil.
- 15.** The structure of claim **14**, wherein a joining region of the first elongated portion and the second elongated portion is overlapped by a center region of the coil.
- 16.** A structure comprising:  
 a molding compound;  
 a device die encapsulated in the molding compound;  
 through-conductors encapsulated in the molding compound, wherein the through-conductors form parts of a coil, and the coil is electrically coupled to the device die;  
 a metal plate with a portion overlapped by the coil, wherein the metal plate is overlapped by both the coil and the device die; and  
 a dielectric region penetrating through the metal plate, wherein the dielectric region comprises:  
 an elongated portion extending directly under the coil, wherein the elongated portion extends to an edge of the metal plate.
- 17.** The structure of claim **16**, wherein the dielectric region further comprises a bulk portion overlapped by the coil, wherein the bulk portion is connected to an end of the elongated portion.
- 18.** The structure of claim **17**, wherein an entirety of the bulk portion is overlapped by a center part the coil.
- 19.** The structure of claim **16**, wherein the dielectric region comprises an air gap.
- 20.** The structure of claim **16**, wherein the through-conductors comprise:  
 top ends substantially coplanar with both a top surface of the molding compound and a top surface of the device die; and  
 bottom ends substantially coplanar with a bottom surface of the molding compound.
- \* \* \* \* \*